

Periodic Poling of Stoichiometric Lithium Tantalate for High-Average Power Frequency Conversion

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Poster Presentation

- AFRL has supported the development of high-average power solid state lasers, often with operating wavelengths in the nearinfrared region of the spectrum
- PPSLT can be used to shift the output wavelengths of these laser systems to other regions of the spectrum to fill specific needs
- Shifting to shorter wavelengths (into the visible region of the spectrum) is useful for adaptive optics (589 nm sodium guidestar radiation); compact visible sources also have great commercial potential (projection displays, biomedical instruments, etc.)
- Shifting to longer wavelengths (into the mid-infrared region of the spectrum) is useful for infrared counter-measures and remote chemical sensing



Physical Properties Responsible for the Promise of PPSLT

- Stoichiometric lithium tantalate (SLT) is a ferroelectric material, which means the unit cell of the crystal has a permanent electric dipole moment and can be re-oriented by applying an electric field ("domain inversion")
- By applying a <u>patterned</u> electric field, one can change a single crystal of SLT into a <u>patterned</u> material, periodically poled SLT (PPSLT); this patterning leads to an increase in the nonlinear optical performance of the material ("quasi-phasematching", QPM)



Physical Properties Responsible for the Promise of PPSLT (Continued)

- In comparison with other ferroelectric materials, SLT has these advantages:
 - it is less susceptible to optical damage, leading to more stable output power at a given temperature and to lower operating temperatures
 - lower electric fields are needed to achieve domain inversion, making it possible to produce thicker crystals with higher power-handling capability
 - it has better transparency in the ultraviolet region of the spectrum, leading to the production of radiation with shorter wavelengths



How to Fabricate and Test PPSLT Devices

- Procure wafer of stoichiometric lithium tantalate (SLT) from an appropriate vendor
- Cover one surface of wafer with a patterned insulator, then apply a metal overcoat to that pattern
- Apply a pulse of high voltage
- Etch the wafer in hydrofluoric acid to reveal the domain pattern
- Dice the wafer into chips and polish the end faces
- Shine a high-power near-infrared laser into one end of the crystal and measure the visible radiation coming out the other end



Periodic Poling Apparatus: Schematic and Photograph

- Computer-controlled system for creating high-voltage pulses, recording current and voltage
- Wafer covered with patterned photoresist, Cr/Au on the plus-Z face; electrical contact using electrolyte-soaked lens tissue





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 Voltage turned off automatically when desired charge or pulse length has been reached PSI Proprietary

Scaling to Short Periods: Macroscopic View

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- Three-inch diameter, 0.5 mm thick wafers from Deltronic Crystal Industries
- Pattern (revealed by etching) contains grating-like structures with periods ranging from 5.8 μ m to 11.2 μ m





- G-2482
- Reproducible, wafer-scale poling process



- Magnified pictures taken of the minus-Z face (the face which did not contain the patterned photoresist)
- QPM gratings with periods 10.8 μm (left), 7.6 μm (right); useful for generating yellow and green radiation, respectively



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Reasonable quality for these periods over a 50-mm length

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Scaling to Still-Shorter Periods: Microscopic View

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• QPM period = 6.0 μ m; useful for generating blue-green radiation



• More work needed to achieve (or better) this quality on wafer scale



Scaling to 2 mm Thickness: Macroscopic, Microscopic Views

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- 50 mm diameter, 2 mm thick wafers used
- QPM period = 17.4 μm; useful for frequency-doubling of telecom lasers





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 Further work needed to minimize domain merges on wafer scale, and to scale the wafer diameter from 50 mm to 76.2 mm

High Power Laser Tests: Schematic and Photograph

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- Q-Peak Nd:YLF input laser based on multi-pass slab (MPS) technology
- Average power up to 6 W at 1047 nm; can be operated in continuous-wave mode, or in a variety of pulse formats





- G-5415
- PPSLT crystals with three different lengths (10, 20, 30 cm) mounted inside resistively-heated oven

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- SHG converts 1047 nm input radiation to 523.5 nm
- Power at 523.5 nm monitored as a function of temperature of PPSLT crystal; QPM grating with period of 7.4 μm, length of 30 mm



 Phase-matching temperature and bandwidth agree reasonably well with predictions based on published Sellmeier equation of Bruner et al. (*Optics Letters*, <u>28</u>, 194-196 (2003))

Laser Testing: Conversion Efficiency in Continuous-Wave Regime

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- SHG efficiency measured as a function of incident power at 1047 nm
- Measured powers corrected for Fresnel reflection losses



- Linear relationship observed, as expected when the input beam is not depleted by the interaction
- Fitted slope gives a device efficiency of 1.0%/W PSI Proprietary

Laser Testing: Calculation of Effective Nonlinear Optical Coefficient

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- Spatial profile of weakly-focused laser beam calculated from known beam properties using Gaussian beam propagation formulas
- Device efficiency given by the following equation:

$$\eta_{dev} = \frac{2\omega_{1h}^2 d_{eff}^2 L^2}{\pi n_{1h}^2 n_{2h} \epsilon_0 c^3 W_0^2}$$

where ω_{1h} is the frequency of the fundamental beam, d_{eff} is the effective nonlinear coefficient, L is the interaction length, n_{1h} and n_{2h} are indices of refraction, and W_0 is the laser spot size

- Calculated value of d_{eff} is 7.4 pm/V, close to the expected value of 10.2 pm/V for an ideal QPM structure with perfect uniformity and perfect phasematching
- This value of d_{eff} can be used in predictions of device performance
- For comparison, periodically poled lithium niobate (PPLN) devices can have d_{eff} = 17 pm/V, but suffer from stability, power handling, and UV transparency issues

Laser Testing: Summary of Performance in Continuous-Wave Regime

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Quantity	Value
Fundamental wavelength	1047 nm
Chip length, L	3.0 cm
η_{dev}	1.0%/W
$\eta_{nor} = \eta_{dev}/L$	0.3%/W-cm
Fundamental power	5.5 W
Second-harmonic power	300 mW

• 300 mW of green radiation generated, with no evidence of beam distortion due to photorefraction



Laser Testing: Conversion Efficiency in Pulsed Regime

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• Data obtained for a variety of QPM periods, pulse formats, and crystal lengths



 Conversion efficiency levels off at ~30% in the 20 mm long chip, lower than expected based on the cw results; small phase-matching errors in the depleted-pump regime may be responsible

Laser Testing: Summary of Best Performance in Pulsed Regime

Quantity	Value
Fundamental wavelength	1047 nm
Laser repetition rate	20 KHz
Laser pulse length	100 ns
Chip length	2.0 cm
Peak conversion efficiency	31%
Fundamental peak intensity	20 MW/cm ²
Fundamental average power	2.5 W
Fundamental pulse energy	125 μJ
Second-harmonic average power	780 mW
Second-harmonic pulse energy	39 μJ

- 780 mW of green radiation generated
- Optical damage (surface and bulk) observed at the highest intensities; more work needed to understand its cause

- Optical parametric oscillators (OPOs) based on congruent lithium niobate (CLN) are limited to wavelengths less than 4 microns because of absorption; reliable absorption data for SLT are not available in the literature
- FTIR spectra taken on X-cut, 1 mm thick wafers of SLT, CLN



 SLT not significantly more transparent than CLN in the 4.0-4.5 micron wavelength range; therefore, PPSLT is not promising for extending OPOs to longer wavelengths PSI Proprietary



- Periodic poling of commercially available SLT wafers from two suppliers (Oxide Corporation and Deltronic) carried out
- Wafer-scale poling achieved for periods as short as 7.3 μm on 0.5 mm thick substrates
- Promising results obtained for periods as short as 5.8 μm on 0.5 mm thick substrates, and for periods as short as 17.4 μm on 2.0 mm thick substrates
- SHG of a Nd:YLF laser in PPSLT has produced 300 mW of average green power in the cw regime, with a device efficiency of 1.0%/W
- SHG has also produced 780 mW of average green power in the pulsed regime, with a conversion efficiency of 31%
- Future work will include extending short-period poling to thicker substrates, examining scaling to higher average powers